Standard amine-thiol solution process: Thiourea/Cysteamine

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1 Back contact preparation

TBC

2 Solution preparation

In air, to an empty vial:

- $\bullet\,$ Add 10ml DI water
- Add 1g cysteamine; leave to dissolve (approx. 1 min)
- Add 1g thiourea; leave to dissolve (approx. 5 mins)
- Add 0.143g Cu(II)O $(1.8 \times 10^{-3} \text{mol})$
- Add 0.098g ZnO $(1.2 \times 10^{-3} \text{mol})$
- Add 0.215g SnSO₄ $(1.0 \times 10^{-3} \text{mol})$
- Leave to dissolve usable within 2-4 hours depending on mixing speed, typically left overnight
- Dilute with:
 - 30ml DI water
 - 4g thiourea

3 Deposition

Deposit onto one 50x50mm Mo substrate using an ultrasonic nozzle. Deposition conditions:

- Flow rate 1.5ml/min
- Stage speed 40 mm/s
- Layers 12
- (Atomisation) power 4.5W
- (Directional) gas pressure 6L/min (nitrogen)
- Hotplate set point 350°C
- Dwell between layers 60s
- \bullet Nozzle-hot plate distance - ${\sim}5.5\mathrm{cm}$
- ullet Post-deposition anneal 3mins

4 Selenisation

Processes two 25x25mm units.

- Load samples into graphite box with 12 Se pellets
- Load graphite box into tube; pump down to singe-digits (torr)
- Flush and purge with N₂ gas (2min flow)
- Selenisation conditions:
 - Starting pressure 80Torr
 - Duration 35mins (including ramp up)
 - Set temp 575° C
- At end of timer open furnace lid; leave to cool naturally (approx. 35mins)
- \bullet Remove when below 50°C

5 CdS buffer layer

Bath samples as soon as possible after removing from vacuum.

- \bullet Set circulating bath to 70°C
- Add 183ml DI water to a beaker; leave to warm
- \bullet Add samples when water temp ${\sim}55^{\circ}\mathrm{C}$
- \bullet When water temp reads 60°C:
 - Add 32.6ml ammonium hydroxide (28-30 wt% solution)
 - $\text{ Add } 25\text{ml } \text{CdSO}_4 \text{ } (0.015\text{M})$
 - Start 15min timer
- After 5mins add 12.5ml thiourea (1.5M)
- When timer ends remove samples and rinse with DI water
- Dry with compressed air

6 Top contact

| | iZnO | AZO |
|--------------------------|---------------|-----------|
| Supplier | Plasmaterials | Innovnano |
| Purity (%) | 99.9999 | 99.9999 |
| Power setpoint (W) | 180 | 180 |
| Target diameter (inches) | 3 | 3 |
| Coat time (s) | 900 | 5400 |
| Gas flow (sccm) | $1\% O_2: 6$ | Ar: 7 |
| Gas now (sceni) | Ar: 5 | A1. 1 |

7 Metal grids

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